高平教授团队与Nature Chemical Engineering期刊编辑部往 来信件



Outlook

RE: Inquiry Regarding Manuscript NATCHEMENG-24122264

发件人 Thomas Dursch <thomas.dursch@us.nature.com>

日期 周三 2025/1/22 15:32

收件人 Xingchen GUO <xquo387@connect.hkust-gz.edu.cn>; Nature Chemical Engineering <ChemEng@springernature.com>

Dear Xingchen,

Thank you for the follow-up email below.

I sincerely apologize for not getting back to you sooner; it's been quite hectic at the journal with many immediate deadlines, increasing submissions numbers, and a short-staffed editorial team.

I will be able to send you more information by the end of this week at the very latest, hopefully sooner. Rest assured that your feedback is important to us and our community.

I appreciate your patience!

Tom

Thomas Dursch Chief Editor **Nature Chemical Engineering**

From: Xingchen GUO <xguo387@connect.hkust-gz.edu.cn>

Sent: Wednesday, January 22, 2025 1:28 AM

To: Nature Chemical Engineering <chemeng@nature.com> Cc: Thomas Dursch <thomas.dursch@us.nature.com>

Subject: Inquiry Regarding Manuscript NATCHEMENG-24122264

Dear Nature Chemical Engineering,

I am writing to kindly inquire about the status of my manuscript (NATCHEMENG-24122264), which was submitted as a Matter Arising. I am aware of your policy regarding comments on articles published within the last 18 months and understand that it typically takes about two weeks to contact the original authors. However, it has been more than one and a half months since my manuscript was received by your journal. Given this timeframe, I believe there has been ample opportunity to communicate with

the authors, especially considering that this is the second instance involving duplication and plagiarism on the same issue. I would be very grateful if you could update me on the progress of this matter. Is there any additional information or documentation that I can provide to assist further?

Thank you very much for your time and assistance. I look forward to your response.

Yours sincerely,

Xingchen Guo AMAT Thrust Function Hub HKUST(GZ)

发件人: Xingchen GUO < xguo387@connect.hkust-gz.edu.cn >

发送时间: 2024年11月25日 17:54

收件人: thomas.dursch@us.nature.com <thomas.dursch@us.nature.com>

抄送: <u>gguab@connect.ust.hk</u> <<u>gguab@connect.ust.hk</u>>; MA Xin <<u>xmaay@connect.ust.hk</u>>; Donghao XIE <<u>dxieaf@connect.hkust-gz.edu.cn</u>>; Runzhi CAI <<u>rcai183@connect.hkust-gz.edu.cn</u>>; Ruohong KE <<u>rke379@connect.hkust-gz.edu.cn</u>>; Shijie YUAN <<u>syuan474@connect.hkust-gz.edu.cn</u>>; Xingwei CHEN <<u>xchen521@connect.hkust-gz.edu.cn</u>>; Hing Ni KO <<u>kejuliako@connect.hkust-gz.edu.cn</u>>; Zenan LI <<u>zli808@connect.hkust-gz.edu.cn</u>>

主题: Concerns about data validality of "Scalable production of critically thin polyethylene films via multistep stretching" in Nature Chemical Engineering

Dear Editor,

We are writing this email to alert you about our concerns regarding the claims made by a recent article by Li et al. published in your journal. The paper is entitled: Scalable production of critically thin polyethylene films via multistep stretching, https://doi.org/10.1038/s44286-024-00139-w.

In the paper, Li et al. described an ultrathin polyethylene (PE) membrane of 12 nm thickness (referred to as C-PE). However, upon recent examination of the data and figures in the paper, we have concerns regarding the author's claims. Drawing on our extensive research experience with PE nanomembranes, we have significant reasons to question the reliability of their findings. For your information, our research group first introduced our invention of the PE nanofilm in 2019 (patent published, Patent No.: US 11,389,772 B2), which garnered media attention at the USPTO (see the USPTO' website:) http://ct.moreover.com/?

a=39612275146&p=1gw&v=1&x=dT2IFaO4tkFpxxCWPcg2-A).

Further details can be found in the attached letter for your perusal.

Yours sincerely,

Xingchen Guo AMAT Thrust Function Hub HKUST(GZ)